

Additions and Corrections

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M. J. MacEachern, H. Dabkowska, J. D. Garrett, G. Amow, Wenhe Gong, Guo Liu, and J. E. Greedan*; Metal-Insulator Transitions in $\text{La}_{1-x}\text{TiO}_3$, $0.0 \leq x \leq 0.33$. Structure-Property Correlations.

Page 2101. The following is a corrected Figure 12.

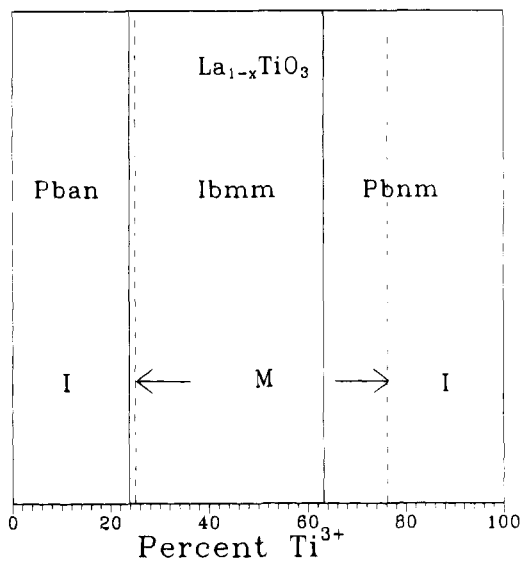


Figure 12. Comparison of the crystal structure and electrical properties as a function of Ti^{3+} concentration in $\text{La}_{1-x}\text{TiO}_3$. The solid vertical lines separate regions of different crystal structure and the dashed lines regions of I (insulating) or M (metallic) behavior.

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